Reductive and Oxidative UV Degradation of PFAS

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Perfluoroalkyl and polyfluoroalkyl substances (PFASs) consist of a group of environmentally persistent, toxic and bio-accumulative organic compounds of industrial origin that are widely present in water and wastewater. Despite restricted use due to current regulations on their use, perfluorooctanoic acid (PFOA) and perfluorooctane sulfonic acid (PFOS) remain the most commonly detected long-chain PFAS.

PFAS UV VUV oxidation water

1. Introduction

Perfluoroalkyl and polyfluoroalkyl substances (PFASs) (C5–C18) are widely used in different industrial applications (clothing, paper packing, non-stick cookware, food packaging, pesticide formulations, waterproof fabrics, fume suppressants, photographic films, masking tape, firefighting foams) due to their unique properties 12 . These special properties of PFASs are associated with characteristics such as: (1) the hydrogen atoms on the alkyl chain are replaced by fluorine atoms 3 , and (2) the presence of both long hydrophobic perfluorinated (C_nH_{2n+1}) carbon chain and hydrophilic functional group (-SO₃⁻, -COO⁻), i.e., in PFOS and PFOA 4 . PFAS have been found in both influent and effluent of wastewater treatment plants which are considered as one of the major sources for their occurrence in surface and groundwater 5 . Like several other micropollutants, PFAS are found at very low concentrations 8 , but their refractory nature and unique physicochemical properties (**Table 1**) exacerbates the challenge of their degradation and/or removal.

 Table 1. Physicochemical properties of various PFASs (adapted from Espana et al. ^[9]).

Property	PFOA (Free Acid)	PFOS (Potassium Salt)
* Physical description	White powder/waxy white solid	White powder PFOA
Molecular formula	C ₈ HF ₁₅ O ₂	C ₈ HF ₁₇ O ₃ S
Molecular weight (g mol ⁻¹)	414	538
Water solubility at 25 $^\circ\text{C}$ (mg L $^{-1})$	9.5×10^{3}	680
Melting Point (°C)	45–50	>400
Boiling point (°C)	189–192	Not measurable

Property	PFOA (Free Acid)	PFOS (Potassium Salt)
Vapour pressure at 25 °C (Pa)	4.2	2.48×10^{-8}
Organic–carbon partition coefficient (log K_{oc})	2.06	** 2.57
Henry's law constant (atm-m ³ mol ⁻¹)	Not measurable	3.05×10^{-9}
Half-Life	*** 90 days, **** >92 years (at 25 °C)	*** 114 days, **** >41 years (at 25 °C)

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* At room temperature and atmospheric pressure, ** Value estimated based on anion and not the salt, *** 1. Baran, J.R. Fluorinated Surfactants and Repellents: 2nd Edition. Revised and Expanded Atmospheric, **** In water. Surfactant Science Series; American Chemical Society: Washington, DC, USA, 2001; Volume

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3.1- Direct Photolysis (UNAVAY), Hong Lien, N.P.; Qiu, Y. New POPs in the water environment:

Distribution, bioaccumulation and treatment of perfluorinated compounds—A review paper. J. UV irradiation is divided into four regions: UVA (315–400 nm), UVB (280–315 nm), UVC (200–280 nm) and Water Supply Res. Technol. Aqua 2007, 56, 313–326. vacuum UV (VUV, 100–200 nm) 10. Low pressure (LP) mercury lamps emitting UVC irradiation primarily at 254 nm Have use Zn; i Resign Sect Boi the; dy anguide of Wangus contrangents including Adars prive beaution frocess for mean anismont perflus ribated is an analysis of the second states and the second derA01stra27C4by453ve4514nvestigations [11][12][13][14]. Little to no degradation during direct UV photolysis is attributed te insufficient breakdown of the C-E bend by photo energy generated during UV irradiation ^[15] Giri et al. ^[15] S. Ahrens, L., Barber, J.L., Xie, Z., Ebinghaus, R. Longitudinal and Latitudinal Distribution of corresponded these results and found negligible degradation of REOA after 5 h of irradiation at 254 nm. The absorption of UV light at wavelength higher than 220 nm is very low resulting in direct photolysis being ineffective for PFAS degradation $\begin{bmatrix} 16 \\ -8 \end{bmatrix}$. Similarly, Chen et al. $\begin{bmatrix} 12 \\ -8 \end{bmatrix}$ observed that the UV absorbance of PFOA from 190 to 280 nm (UVE) abinker Wied avan Asseldonku & absorption Hyper VSV reg Brosence of Emerging Per- and Polyfluoroalkyl Substances (PFASs) in River and Drinking Water near a Fluorochemical GiriProdute on Riant in the Northerlands o Ebuir on Sci 7 Technolo 2912 nd 51 w 1257 nh 19646.8 kJ mol-1) and Considering the C-B boad energy (347 K) mol⁻¹, PEOA is prone to breakage by both wavelengths. However, C-F bond with the higher bond energy (552 k) mol⁻¹) is unlikely to be cleaved by 254 nm. It is therefore established that direct UV photolysis at 254 nm is not a suitable process for the degradation of these compounds. Considering effluents of an industrial wastewater treatment plant. Chem. Eng. J. 2017, 322, 196–204. the higher photon energy generated during VUV photolysis, direct photolysis by VUV is more promising. 8. Ahrens, L. Polyfluoroalkyl compounds in the aquatic environment: A review of their occurrence Although father Jaten winner Manies 2914 , V.B. 2 Packation, the findings suggest that the process has the potential to degrade PEAS. Considering stronger, UV absorption below 200 nm, the application of VUV photolysis requires to 9. España, V.A.A., Mallavarapu, M., Naidu, R. Treatment technologies for aqueous ising specially designed system emitting most irradiation at 185,0m, such as in the case of be investigated tur berilubrooctal Giri et al. [12] who reported 97% VLIV emission when used a synthetic fused silica glass tube. It is worth noting that emphasis on field testing. Environ. Technol. Innov. 2015, 4, 168–161. the VUV process generates ozone that could also lead to the degradation of PFAS. However, none of the studies

have looked at the generation and potential degradation of PFAS related to ozone produced during VUV process.

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anions ^[17]. The addition of chemicals could therefore be avoided during VUV process due to in-situ generation 11. Chen, J.; Zhang, P. Photodegradation of perfluoroctanoic acid in water under irradiation of 254 H_2O_2 ^{[18][19]}. Hence, it is important that VUV process is investigated with a particular focus given to optimizing nm and 185 nm light by use of persulfate. Water Sci. Technol. 2006, 54, 317–325. conditions for greater generation of H_2O_2 . The role of ozone generated during VUV process also needs to be

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15nf&voraBleRforQFakiegradatorder FFJAniguedoi, SmpTakiaeanoisoRpti5actopsionflyearingheVipper limit for the seconderentersitientofportiverentianpiperial in vater-64 (19. 2001, In2012, 18 Aich 97 52 Val orders

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less thermodynamically favored HO⁻ ($E^0 = 1.9 \text{ V}$). The perfluorination or substitution of organic hydrogen atoms for

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2.2.2.2. UV/VV/Suffice induced photolysis via hydrogen peroxide formation, iodine species change,

and difluoroacetic acid degradation. Front. Environ. Sci. Eng. 2022, 16, 55.

- A comparison between VUV alone and in combination with K₂S₂O₈ and Na₂S under oxygen and nitrogen 20. Hori, H.; Hayakawa, E.; Einaga, H.; Kutsuna, S.; Koike, K.; Ibusuki, T.; Kiatagawa, H.; Arakawa, atmosphere, respectively, was made for the degradation of perfluorodecanoic acid (PFDeA) ^[24]. The degradation of R. Decomposition of Environmentally Persistent Perfluorooctanoic Acid in Water by PFDeA was ~60% after 5 h irradiation (light intensity of 62–69 mW cm⁻²) but a much lower defluorination ratio of Photochemical Approaches. Environ. Sci. Technol. 2004, 38, 6118–6124. ~16% was achieved using VUV alone. However, in the presence of K₂S₂O₈ under oxygen atmosphere, the
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decomposition by SO4^{•-} was proposed during VUV/K2S2O8 process with SO4^{•-} playing a significant role in the 23xiGatheoder, Hation Moreptora, Rounting bility Rashing the originated surfactants in advanced and detion or obesees degradation occurred bup ho conclusion products using flow injection was spectrometry liquide requiring this

system to be investigated further. The PFOA degradation pathway during UV-based AOPs including SO4* is given

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- 30. Jin, L.; Zhang, P.; Shao, T.; Zhao, S. Ferric ion mediated photodecomposition of aqueous Figure 1. Degradation pathways of PEOA during UV-based AOPs (adapted from Wang et al. ^[25]. perfluorooctane sulfonate (PFOS) under UV irradiation and its mechanism. J. Hazard. Mater.

2.3. Reaction by-Products during UV/VUV Photodegradation

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Investigating PFOA degradation using VUV/Fe³⁺, Cheng et al. ^[26] identified intermediate by-products containing C_2-C_7 perfluoroalkyl groups in agreement with previous investigations ^{[12][20]}. The longer chain intermediates including PFHpA (C_7) and perfluorohexanoic acid (PFHxA) (C_6) reached maximum concentration after 1.5 h and 3 h, respectively, followed by decreased concentration with increasing irradiation time. The remaining intermediates (C_2-C_5) increased throughout the 4 h irradiation period. The order of concentration followed PFPeA > PFBA > perfluoropropionic acid (PFPA) > trifluoroacetic acid (TFA) demonstrating the longer chain intermediates appeared at the start of the reaction followed by decomposition to shorter chain products. Investigating PFOA degradation using 254 nm UV during UV/H₂O₂/Fe²⁺ process, Tang et al. ^[27] found that the degradation intermediates included the short chain perfluorocarboxylic acids containing 2, 3 4, 5 and 6 carbon atoms and fluoride ions which is in agreement with others ^{[15][28]}. Liang et al. ^[29] also identified perfluoronated carboxylic acids with 2–7 carbon atoms during VUV/Fe³⁺ degradation of PFOA. It was further noted that the shorter chain degradation products were higher in concentration, i.e., PFPA > PFBA > PFPeA > PFHxA > PFHA ^[29]. Jin et al. ^[30] while investigating the degradation of PFOS using UV/Fe³⁺ found C₂–C₈ PFCAs in addition to sulphate and fluoride as degradation by-products. Theses intermediates are similar to that reported in earlier studies using UV/Fenton ^[27] and VUV/Fe³⁺ ^[29].

2.4. Photochemical Oxidation Using MP UV—Impact of Experimental Conditions

Some studies have investigated the degradation of PFAS using medium pressure UV lamps. For example, Hori et al. ^[16] investigated photochemical degradation using MP UV lamp (220–460 nm) of PFCAs containing 3–5 carbon atoms (PFPrA, PFBA, or PFPeA). They reported that the absorption of UV light was much higher for deep-UV region to 220 nm but was much lower for 220–270 nm. After 24 h of direct photolysis, 24.3% of PFPeA was degraded yielding 12.1% F⁻. The other two PFCAs (PFPrA, PFBA) showed lower but comparable degradation and F⁻ yield of about 16% and <10%, respectively. Degradation of these short chain PFAS enhanced when 5 mM Fe³⁺ was used such that the degradation of PFPeA, PFBA and PFPrA was about 2.7-, 3- and 3.8-fold greater when compared with UV alone after 24 h. Similarly, the amount of F⁻ yield was greater although it did not follow the trend of degradation. The degradation followed pseudo-first-order kinetics with increasing rate of degradation with increasing initial concentration of PFPeA demonstrating that the complexes formed between Fe³⁺ and PFPeA resulted in photo-redox reactions that led to the formation of Fe²⁺ and oxidized PFPeA. The degradation of PFPeA was markedly higher in the presence of oxygen (64.5%) than argon (35.6%) and so was the conversion of Fe³⁺ to Fe²⁺, i.e., 93.3% and 0.70%, respectively. It was concluded that oxygen was required for re-oxidation step of Fe²⁺ conversion to Fe³⁺ since the presence of oxygen could increase the formation of HO₂ that can expedite the re-oxidation process.